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Migliaccio, C. P. and Garimella, S V., "Dissipative Forces in the Electrowetted Cassie-Wenzel Transition on Hydrophobic Rough Surfaces" (2012). CTRC Research Publications. Paper 179. http://dx.doi.org/10.1080/15567265.2012.683935

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DISSIPATIVE FORCES IN THE ELECTROWETTED CASSIE-WENZEL TRANSITION ON HYDROPHOBIC ROUGH SURFACES

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Dissipative forces in the electrowetting-induced Cassie-Wenzel transition on hydrophobic rough surfaces are explored. High-speed imaging of droplet shape evolution during the electrically induced spreading process allows for the location of the contact line to be tracked as a function of time. A surface energy analysis quantifies the total energy dissipated via non-conservative forces during the spreading process. Though identified as the dominant dissipative effect in droplet spreading on smooth surfaces, contact line friction is shown to have relatively weak influence on the spreading on rough surfaces.

#### INTRODUCTION

Electrowetting<sup>1</sup> (EW) on structured superhydrophobic surfaces<sup>2, 3</sup> is a promising droplet manipulation technique with potential microfluidic and heat transfer applications. EW in this setting is typically used to transition a droplet between the two wetting extremes –the Cassie state,<sup>4</sup> where the droplet rests on top of the roughness elements of the surface (and on the air in the inter-element spaces), and the Wenzel state,<sup>5</sup> where the droplet wets, and is in intimate contact with, the roughness elements. In most cases, once the Wenzel state is achieved, the Cassie state cannot be recovered,<sup>2</sup> thus practical applications are currently limited. Recent

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efforts<sup>6-9</sup> have focused on developing methods to overcome the dissipative forces<sup>10</sup> and energy barriers<sup>10, 11</sup> that hinder a complete Wenzel-Cassie reverse transition.

Methods to reduce the influence of dissipative forces in the electrical actuation of droplets have been explored. The effective frictional force arising from molecular adsorption and desorption processes around the contact line is thought to be the dominant dissipative effect in the actuation of liquids on smooth surfaces. Quantitative estimates of contact line friction have generally relied on the description of Blake and Haynes, who proposed a linearly proportional relationship between friction associated with these molecular processes and the contact line velocity, *i.e.*,

$$F_{CL}' = \xi U_{CL} \tag{1}$$

where  $F_{CL}$  is the contact line friction force per unit length of the wetting line,  $\xi$  is the friction factor (N s/m<sup>2</sup>), and  $U_{CL}$  is the velocity of the contact line. This expression has been used in various modeling efforts<sup>17, 18, 21-23</sup> to determine the value of  $\xi$  based on experimental observations of liquids spreading on smooth surfaces.

The energy dissipated due to non-conservative forces during a Cassie-Wenzel transition has not been experimentally quantified to date, to the best of the authors' knowledge. In this article, we quantify the dissipative effects and determine the role of contact line friction in EW-induced spreading on a variety of highly hydrophobic surfaces with engineered roughness elements, under a range of actuation voltages. The findings from this work will further the design and modeling of superhydrophobic surfaces.

#### EXPERIMENTAL SET-UP AND PROCEDURES

Cleanroom-grade deionized (DI) water droplets with an electrical resistivity of  $1.80 \pm 0.02$  $M\Omega$  cm (4-wire method, Agilent 34411A) are used in the experiments. The laboratory environment is maintained at  $21.0 \pm 0.3$  °C at a  $30 \pm 2$  % relative humidity. Highly doped silicon wafers with a dielectric layer of 1 µm thermally grown oxide serve as the substrates. SU-8 negative photoresist (MicroChem Corp.) is spin-coated and patterned using standard lithography processes to yield arrays of square pillars. The taller pillars exhibit some rounding of the vertical edges and a negative taper from the tip to the base due to imperfect contact during exposure (see Table 1). A scanning white-light interferometer (New View 6200, Zygo, Inc.) with 50× Mirau objective is used to accurately assess the pillar shapes (measurement uncertainty  $\pm 0.06 \mu m$ ). By measuring the pillar width a and diagonal  $a_d$  (see Appendix A), the pillar tip area  $A^*$  and perimeter P may be calculated (uncertainty < 1%). The ratio  $a/a_d$  is a measure of pillar roundness (i.e.,  $a/a_d = 1/\sqrt{2}$  for square pillars and  $a/a_d = 1$  for circular pillars). A thin, conformal coating of Teflon (AF 1600, DuPont; 1% by weight in 3M FC-77, spun at 1500 rpm for 30 s, baked at 95° C for 45 min) renders the surface hydrophobic. An additional wafer is prepared with identical oxide and Teflon layers – but without SU-8 pillars – to serve as a smooth surface reference. Table 1 lists the pillar height h, width a, diagonal  $a_d$ , and pitch b of the surfaces tested, along with the dimensionless roughness parameters  $\phi$  and  $r_m$ , and the initial contact angle of DI water on the surfaces,  $\theta_0$ , as measured by an automated goniometer (Model 590, Ramé-Hart Instrument Co.).  $\phi$  is the ratio of the total pillar tip surface area to the total footprint area of the substrate (i.e.,  $\phi = A^*/b^2$ ), and  $r_m$  is the ratio of the total surface area (including the tips and sidewalls of the pillars and the exposed base) to the total footprint area (i.e.,  $r_m = 1 + Ph/b^2$ ).

Rough surfaces are also characterized by the contact angle hysteresis  $\Delta\theta$ ,<sup>24</sup> which is the difference between the advancing and receding contact angles of droplets. For pillared surfaces, the hysteresis is dependent on the droplet state – Cassie or Wenzel – and is related to the roughness parameters, with hysteresis in the Cassie state being a function of  $\phi$  and hysteresis in the Wenzel state being a function of  $r_m$ .<sup>25</sup> Figure 1 presents the measured contact angle hysteresis for the surfaces in this work. The hysteresis for the reference smooth surface is  $9 \pm 1^\circ$ .

A schematic diagram of the test setup is shown in Figure 2. A droplet of DI water (average volume 1.6 μl, standard deviation 0.8 μl) is gently deposited on the test surface using a syringe. The dynamics of the droplet deposition are not considered in this work; rather, the displacement of the contact line during an EW-induced Cassie-Wenzel transition is investigated. Droplets in this study are much smaller than the capillary length (2.7 mm for water), and hence flattening of the droplets by gravity is neglected. The droplets take on a spherical cap shape on the surface; the volume is determined from optical measurements (resolution 7.7 μm/pixel) by

$$\forall = \frac{4}{3} \pi R_{\text{max}}^{3} - \frac{1}{6} \pi \left( R_{\text{max}} \left( 1 - \sin \theta_{0} \right) \right) \left( 3R_{\text{wet}}^{2} + \left( R_{\text{max}} \left( 1 - \sin \theta_{0} \right) \right)^{2} \right)$$
 (2)

where  $R_{max}$  and  $R_{wet}$  are the maximum and wetted radii, respectively (see Figure 2). The uncertainty in the volume calculations is < 1%.

All droplets are initially in the Cassie or "rolling-ball"<sup>26</sup> state, as evidenced by the ease with which they can be dragged along the top of the pillars or blown off with a gentle stream of nitrogen gas. Moulinet and Bartolo<sup>27</sup> showed that droplets evaporating from superhydrophobic surfaces can gradually transition from the Cassie state to the Wenzel state by way of the 'partial impalement' regime, where the droplet bottom interface sags and slowly moves down the pillar

sidewalls. In the present work, the time from deposition to electrical actuation is on the order of seconds; therefore the partially impaled droplet state is avoided. Voltage bias is applied using a high-voltage power supply between a 125 µm diameter chrome wire electrode inserted into the droplet and an electrode contacting the backside of the silicon substrate. The voltage required to trigger a Cassie-Wenzel transition is dependent on the dielectric properties of the test surface, physical properties of the liquid, and the equilibrium contact angle of the liquid on the reference smooth surface. The observed transition voltages for the test surfaces range from ~75-200 V; surfaces with taller pillars require higher voltages. Voltage in excess of that needed to trigger a Cassie-Wenzel transition is applied to guarantee that the Wenzel state is achieved (see Table 1). The transition is recorded by a high-speed camera (Photron Fastcam Ultima APX) at 10,000 frames per second. Figure 3 presents the Cassie-Wenzel transition of a droplet on surface 5 under an EW voltage of 400 V. The Wenzel state is realized ~ 1 ms after application of the actuation voltage; the contact line then moves in the radial direction, advancing through the pillars until the EW-induced spreading ceases.

#### **RESULTS AND DISCUSSION**

Figure 4(a) shows representative images during the shape evolution of a droplet on surface 1 at an EW voltage of 400 V. The contact line of the droplet (on both sides) is tracked as a function of time, and the displacement from its initial position is recorded. Figure 4(b) reports the contact line displacement for surface 1 at three applied EW voltages; corresponding movie files are available as supplementary material.<sup>29</sup> Higher voltages lead to larger contact line displacements and higher contact line velocities (ranging from 1 to 10 cm/s in this work). Stickslip behavior,<sup>30</sup> where the contact line is periodically pinned and then slips between adjacent rows of pillars, is observed in the spreading process. Other non-conservative effects such as

contact line friction, <sup>16, 17</sup> hysteresis effects, <sup>31</sup> and viscous shear <sup>32</sup> at the solid-liquid interface of the wetted base and pillars retard the spreading process and dissipate energy from the system.

The total energy dissipated during the EW-induced Cassie-Wenzel transition is found by analyzing the droplet shape before and after the transition. Initially, the droplet is in the Cassie state; at the instant the EW voltage V is applied, the surface energy given as

$$E_{C,0} = \left[ A_{LA} + A_{SL} \left( 1 - \phi \right) \right] \gamma_{LA} + \phi A_{SL} \left( \gamma_{SL} - \gamma_{SA} \right) - E_{C,cap}$$

$$\tag{3}$$

where A and  $\gamma$  are the interfacial area and energy, respectively, and  $E_{C,cap}$  is the effective reduction in interfacial energy due to capacitive energy storage in the dielectric layer during EW.<sup>1</sup> The subscripts LA, SL, and SA distinguish between the liquid-air, solid-liquid, and solid-air interfaces, respectively. The application of the EW voltage triggers a transition to the Wenzel state and subsequent radial motion of the contact line. The total surface energy of a droplet in the electrowetted Wenzel state after the EW-induced spreading has ceased (*i.e.*, the contact line motion has stopped) is then expressed as

$$E_{W,EW} = A_{LA}\gamma_{LA} + \phi A_{SL} \left(\gamma_{SL} - \gamma_{SA}\right) + \left(1 - \phi\right) A_{SL} \left(\gamma_{SL} - \gamma_{SA}\right) + \left(r_{m} - 1\right) A_{SL} \left(\gamma_{SL} - \gamma_{SA}\right) - E_{W,cap} \quad (4)$$

where  $E_{W,cap}$  is the interfacial energy reduction during EW when the droplet is in the Wenzel state. The non-uniform thickness and dissimilar materials (SU-8, SiO<sub>2</sub>, and – when the droplet is in the Cassie state – air) of the dielectric layer complicate analytical modeling of the capacitive energy storage of the surfaces;<sup>28</sup> hence the energies  $E_{C,cap}$  and  $E_{W,cap}$  are determined by modeling 3-D unit cells of each surface and actuation voltage using COMSOL Multiphysics software.<sup>33</sup> Since a DC voltage bias is used in this work, the liquid behaves as a perfect conductor;<sup>34</sup> thus the voltage boundary condition is applied between the silicon substrate and the SL interface for the Wenzel state cases, and between the silicon substrate and composite SL-LA interface for the Cassie state cases.

The total energy lost due to dissipative effects  $E_{loss}$  is equal to the difference between Eqs. 3 and 4. The energy dissipated due to the effective friction of the molecular displacement process at the contact line,  $^{20}$   $E_{CL}$ , is found by integrating the friction force around the contact line and over the distance it moves during the EW-induced spreading:

$$E_{CL} = 2\pi r_m \int_{x_0}^{x_{EW}} F_{CL}' x dx = 2\pi r_m \int_{x_0}^{x_{EW}} \xi U_{CL} x dx$$
 (5)

where x is the radial coordinate of the contact line and the subscripts  $\theta$  and EW denote the location of the contact line initially (at the instant the EW voltage is applied) and after the EW-induced spreading has ceased, respectively. It is clear that as the contact line moves over pillared areas of the substrate, the contact line length is extended due to wetting of the pillar sidewalls, thus making the case at hand more complex than spreading on a smooth surface. The enhanced wetted surface area increases the magnitude of the effective friction at the contact line; however, the extent of increase is difficult to quantify since the contact line extension varies with position on the surface. In this work, we modify the contact line length by the roughness parameter  $r_m$  to account for the enhanced wetted surface area. The friction factor  $\xi$  is found by recording the spreading process of a droplet under EW bias on the smooth reference surface. Assuming that contact line friction dominates in this smooth surface case,  $^{16-18}E_{CL}$  is equated to  $E_{loss}$ , yielding a friction factor of 0.39 N s/m<sup>2</sup>. Wang and Jones Previously reported a friction factor range of  $\sim$ 0.2-0.6 N s/m<sup>2</sup> for DI water on a smooth surface under DC actuation. Past investigations Preported little or no dependence of  $\xi$  on EW voltage; therefore,  $\xi$  is assumed to be independent of voltage in this work, and we set  $\xi = 0.39$  N s/m<sup>2</sup> in the analysis of the results.

Since droplet volumes between runs are not identical (1.6  $\pm$  0.8  $\mu$ l), the energy lost to non-conservative forces is considered on a per-change-in-contact-line-length basis *i.e.*,  $E'_{loss} = E_{loss} / \left[ 2\pi \left( x_{EW} - x_0 \right) \right], \text{ to allow for an un-biased comparison.}$  Figure 5 shows  $E'_{loss}$  and

 $E'_{CL}$  as a function of the surface roughness parameter  $r_m$ , at the different EW voltages applied. The solid lines represent the average energy lost to contact line friction forces for each EW voltage level (*i.e.*,  $E_{CL}$  calculated as discussed above). Contact line friction accounts for an average of approximately 30% and 10% of total energy dissipated for the 100 V and 400 V runs, respectively. This is in stark contrast to the dominant role contact line friction forces are reported to play in the spreading process on smooth surfaces. At higher actuation voltages, the degree of spreading is enhanced, so that dissipative effects related to the number of pillars encountered, such as viscous drag forces and stick/slip of the contact line, become more pronounced. Delineating the respective individual roles of these other effects and determining the appropriate approach to describe the contact line as it spreads through the elements of a rough surface will require additional experimental and modeling efforts.

#### **CONCLUSIONS**

This article reports on the use of surface energy analysis to quantify dissipative effects in Cassie-Wenzel transition experiments with droplets on structured-roughness hydrophobic surfaces. Unlike past investigations on smooth surfaces, molecular-level contact line friction forces are shown to have relatively weak influence on spreading processes on rough surfaces. Other dissipative effects amplified by the presence of the roughness elements such as viscous shear forces and stick/slip of the contact line are identified from experimental measurements as being important in this work. These findings will prove useful in the design of superhydrophobic surfaces, and foster the development of new applications.

#### **ACKNOWLEDGEMENTS**

The authors acknowledge financial support for this work from the Cooling Technologies Research Center, a National Science Foundation Industry/University Cooperative Research Center at Purdue University. Vaibhav Bahadur provided helpful feedback and suggestions regarding this work. The SEM images were obtained by Christopher Meyer.

#### APPENDIX A: PILLAR SHAPE ASSESSMENT

Accurate assessment of pillar shapes is crucial in the calculation of the dimensionless roughness parameters  $\phi$  and  $r_m$ . The taller pillars in this work exhibited some rounding of the vertical edges (see Table 1). By measuring the pillar width a and diagonal  $a_d$ , and taking the rounded vertical edges of the pillars to be an arc, the length l (see Figure A1) is given by

$$l = \sqrt{\left(\frac{a_d}{2}\right)^2 - \left(\frac{a}{2}\right)^2} \tag{A1}$$

The chord length c and central angle  $\alpha$  are then

$$c = \sqrt{2} \left( \frac{a}{2} - l \right) \tag{A2}$$

$$\alpha = 2\sin^{-1}\left(\frac{c/2}{a_d/2}\right) \tag{A3}$$

The pillar tip area  $A^*$  and perimeter P may then be calculated as

$$A^* = 4\left(\frac{a}{2}l + \left(\frac{a_d}{2}\right)^2 \frac{\alpha}{2}\right) \tag{A4}$$

$$P = 4\left(2l + \frac{a_d}{2}\alpha\right) \tag{A5}$$

By accounting for the actual pillar shape in this way, significant errors (up to  $\sim 20\%$  for surface 7) in the calculation of  $\phi$  and  $r_m$  that would be introduced by assuming the pillar shapes to be square are avoided.

## NOMENCLATURE

A	interfacial area	Greek		
$A^*$	pillar tip area	$\alpha$	central angle	
a	pillar width	γ	interfacial energy	
$a_d$	pillar diagonal	$\varDelta  heta$	contact angle hysteresis	
b	pillar pitch	$ heta_0$	static contact angle	
c	chord length	ξ	contact line friction factor	
E	energy	$\phi$	ratio of pillar tip surface area to footprint area	
E'	energy per unit length of wetting line			
$F'_{CL}$	contact line friction force per unit length of wetting line	Subscripts		
h	pillar height	C	Cassie state	
l	length defined in Eq. A1	cap	capacitive	
P	pillar perimeter	CL	contact line	
$R_{max}$	maximum radius	EW	electrowetted state	
$R_{wet}$	wetted radius	LA	liquid-air	
$r_m$	ratio of total surface area (pillars and base) to footprint area	loss	dissipative loss	
$U_{CL}$	contact line velocity	SA	solid-air	
V	electrowetting voltage	SL	solid-liquid	
X	radial coordinate	W	Wenzel state	
		0	state at instant electrowetting voltage is applied	

### Symbols

∀ volume

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Table 1. Pillar geometry, roughness parameters, static contact angles, and actuation voltages of the surfaces tested. Pillar dimensions were chosen such that some surfaces would have similar  $\phi$  or  $r_m$  while having different h, a, and b. Scanning electron microscope (SEM) images of select test surfaces are included in the final column. The measurement uncertainty in pillar geometry is  $\pm$  0.06  $\mu$ m.

Surface	$h, a, a_d, b$ ( $\mu$ m)	$\phi$ , $r_m$	$\theta_0$ (degrees)	Actuation voltages (V)	Representative SEM images
0	n/a, smooth	1, 1	113 ± 1	200	Surface 1
1	11, 20, 28, 31	0.43, 1.93	$138 \pm 4$	100, 200, 400	
2	11, 20, 28, 25	0.66, 2.42	$135\pm3$	200, 400	1.9 KV <1.00K 30(6/4)
3	24, 21, 25, 40	0.26, 2.10	$147\pm3$	200, 400	Surface 3
4	24, 22, 24, 31	0.44, 2.81	$139\pm2$	200, 400	TORO
5	39, 22, 23, 57	0.13, 1.87	$145\pm2$	400	Surface 6
6	39, 23, 24, 40	0.28, 2.83	$142 \pm 2$	400	500
7	39, 24, 25, 31	0.49, 4.13	125 ± 6	400	1.0 KV ×1.00K 34: W/4

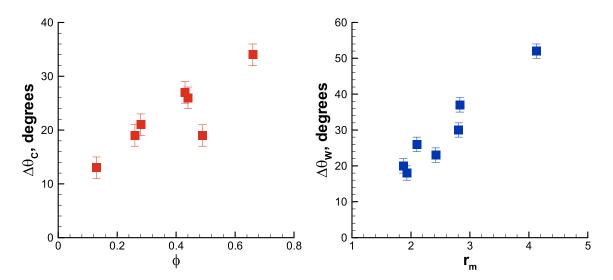


Figure 1. (Color online) Measured contact angle hysteresis in the Cassie and Wenzel states for the rough surfaces tested.

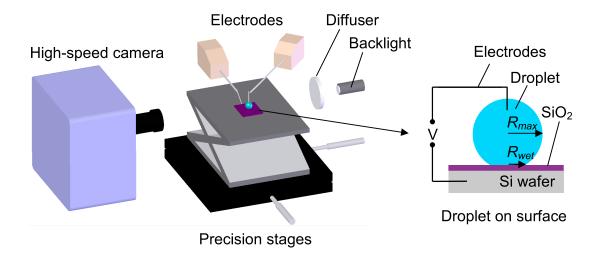


Figure 2. (Color online) Schematic diagram of test setup. The electrowetting voltage bias is applied between a wire electrode inserted into the droplet and an electrode contacting the silicon substrate.

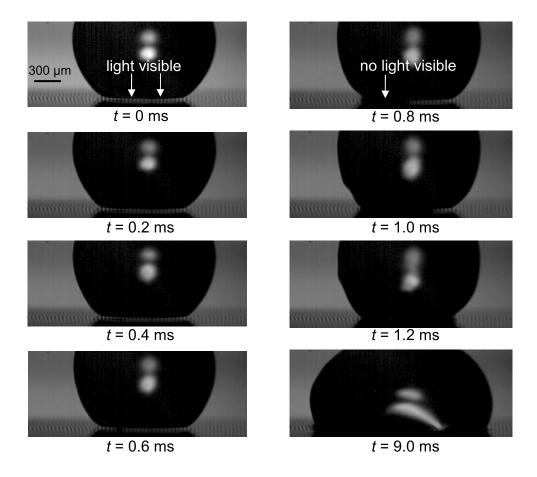


Figure 3. Electrowetting-induced Cassie-Wenzel transition of a 2.3  $\mu$ l water droplet on surface 5 under an EW voltage of 400 V. Light is visible in the pillar interstices because surface 5 has relatively tall (39  $\mu$ m) pillars and low  $\phi$  (0.13). Our setup did not allow for light in the pillar interstices to be observed in other cases.

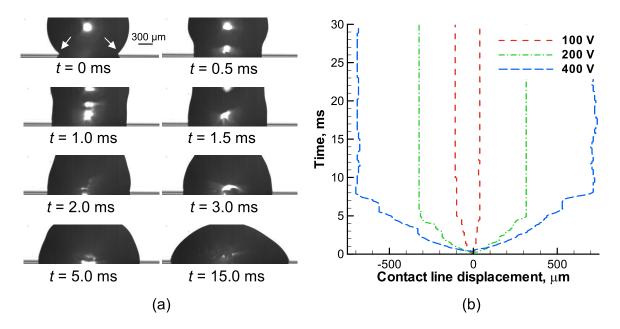


Figure 4. (Color online) (a) Droplet shape evolution of a 2.4  $\mu$ l water droplet during electrowetting-induced spreading on surface 1 at 400 V. The contact line (noted by arrows in the first pane) on both sides of the droplet is tracked through time. (b) Displacement of the contact lines during the spreading process relative to the initial position, 0, for water droplets on surface 1 at electrowetting voltages of 100, 200, and 400 V. Higher actuation voltages result in higher contact line velocities, as evidenced by the slope of the displacement vs. time plot. The uncertainty in position is  $\pm$  3.8  $\mu$ m.

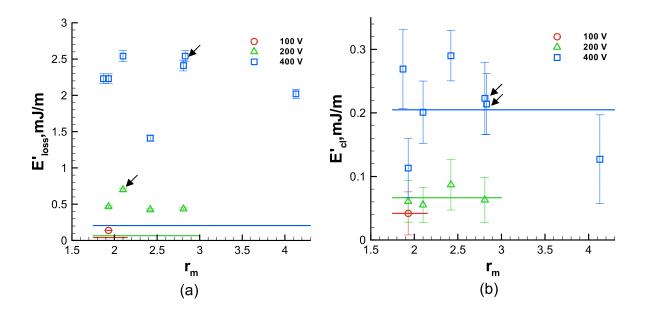


Figure 5. (Color online) (a) Total dissipative energy losses per change in contact line length as a function of surface roughness  $r_m$  at different actuation voltages. (b) Estimated energy losses due to contact line friction forces per change in contact line length as a function of surface roughness  $r_m$  at different actuation voltages. In (a) and (b), symbols represent the average of three data points for each test condition. The standard deviation of the three data points for each test condition is generally between 5% and 25%, except for the cases noted by black arrows (standard deviation ~40%). Error bars represent the propagated uncertainty due to measured quantities. Since  $E'_{CL}$  is a function of contact line velocity, uncertainty is dominated by measurement resolution of contact line position ( $\pm$  3.8  $\mu$ m) and time ( $\pm$  0.05 ms). The solid lines represent the average estimated energy losses due to contact line friction forces at each actuation voltage.

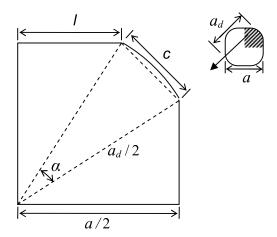


Figure A1. Plan view of a pillar tip showing the two measured dimensions a and  $a_d$  with the quadrant used for the calculations. Taking the rounded corner of the pillar to be an arc, the pillar tip area and perimeter are calculated.